

AN OVERVIEW OF LINAC ION SOURCES

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*2008 Linac Conference, Victoria, B. C., Canada
Sept. 28 – Oct. 3, 2008*

Scope Limitations for this Presentation

- **Sources for high-duty-factor rf Linacs**
 - 5% - cw
- **Tutorial character**
 - Taking the 'Sourcery' out of Ion Sources
- **No attempt at encyclopedic format**
 - Fundamentals
 - Major lines of development
 - Key operational parameters
 - General and type-specific limitations and problems
- **Peak sample results included**
- **Not included**
 - Penning (PIG)
 - Duoplasmatrons
 - Duopigatrons
 - Beam formation issues in detail
 - LEBTs

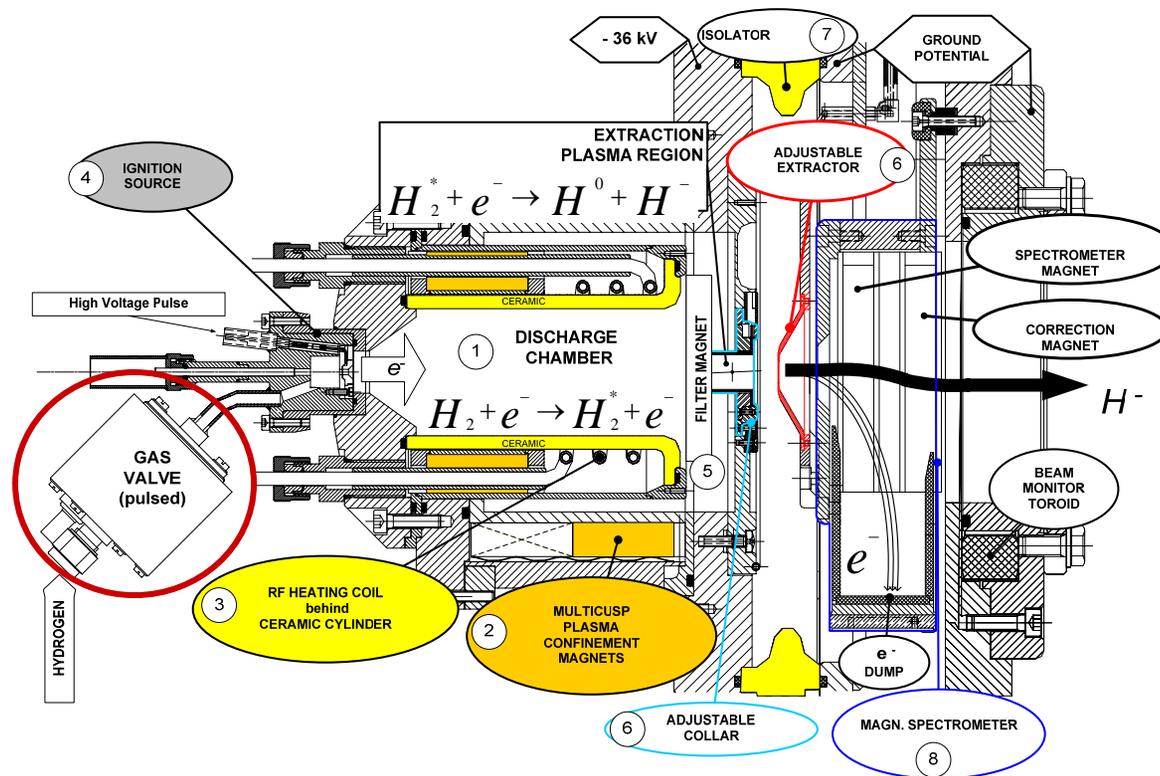
Contents

- **Introduction** (*already given*)
- **Particle feeding methods**
- **Plasma generation**
 - Filament driven
 - Rf driven
- **Multicusp sources**
 - Filament driven
 - Rf driven
- **ECR Ion Sources**
 - ECRIS for Highly charged Ions
 - ECRIS as Charge Breeders
 - ECRIS for High-current Beams

Particle Feeding Methods (1)

Materials in pure, gaseous form

- Needle valve
- Regulated valve
 - May need fast-pulsed valve to reduce average pressure in LEBT



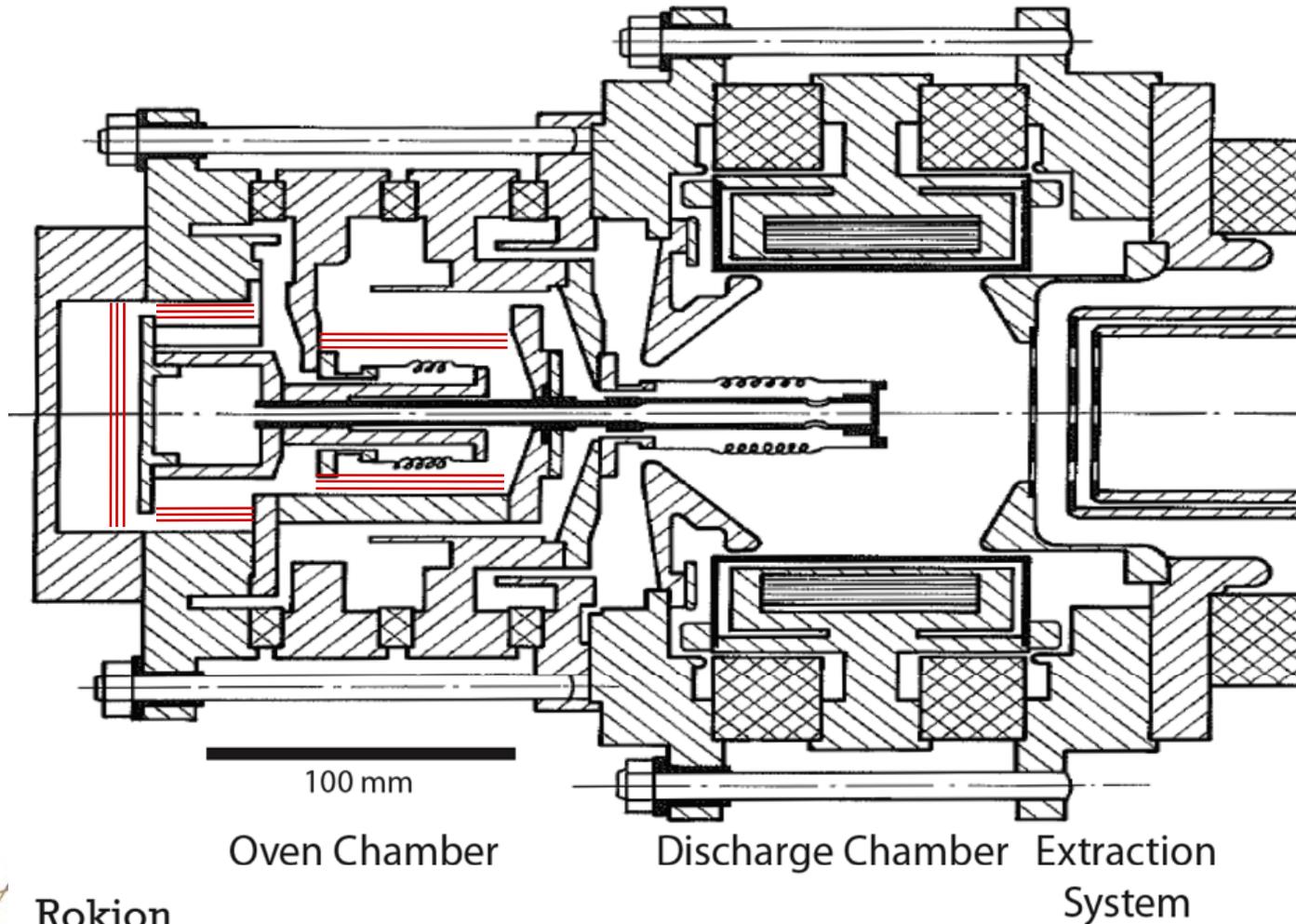
Particle Feeding Methods (2)

Non-gaseous elements

- **Gaseous compounds**
 - e. g., **C** from CO_2
- **Liquid compounds with sufficient vapor pressure**
 - e. g., **B** from BF_3
 - Many compounds contain an **aggressive component**
 - **Erosion** of source parts, especially hot filaments
 - Increased **sparking** rate in extraction system
- **Oven**
 - Need to limit re-condensation material fed into source
 - **Oven should be coldest of internal source parts**
 - Dual heating systems
 - Might benefit from auxiliary gas to stabilize discharge

Particle Feeding Methods (3)

CHORDIS with oven



Particle Feeding Methods (4)

Cathode sputtering

- **Technique well suited for high-melting materials**
 - Dedicated sputtering electrode
 - Biasing existing electrode
 - Made from, or coated with, material of interest
 - Needs auxiliary gas to release desired particles from electrode
 - Self-sputtering does occur but is not a stable process
 - **Sputtering current regulates share** of desired species in plasma
 - Maximum 10-20%
 - Need to limit re-condensation of sputtered material
 - Similar solution as with oven

Plasma Generation (1)

Creating and maintaining a discharge (NOT: arc)

- **Sustained by dc power and thermionic cathodes (filaments)**
 - Continuous (dc)
 - Pulsed
- **Sustained by rf power**
 - Continuous (cw)
 - Pulsed (modulated)
- **Choice of discharge voltage and current values influences plasma composition**
 - Total beam current
 - Singly or multiply charged ions
- **Cathode filaments**
 - Tungsten, tungsten/rhenium or tantalum wire
 - Lifetime limitations
 - Resistance-increase data for diagnostics
 - Earth-alkaline oxide paste on nickel or platinum mesh
 - Used for hydrogen feeding gas (low sputtering rate)

Plasma Generation (2)

Filament lifetime assessment for dc discharges, *R. Keller et al., NIBS Conf. 2008*

'Creep' phenomenon for material under stress

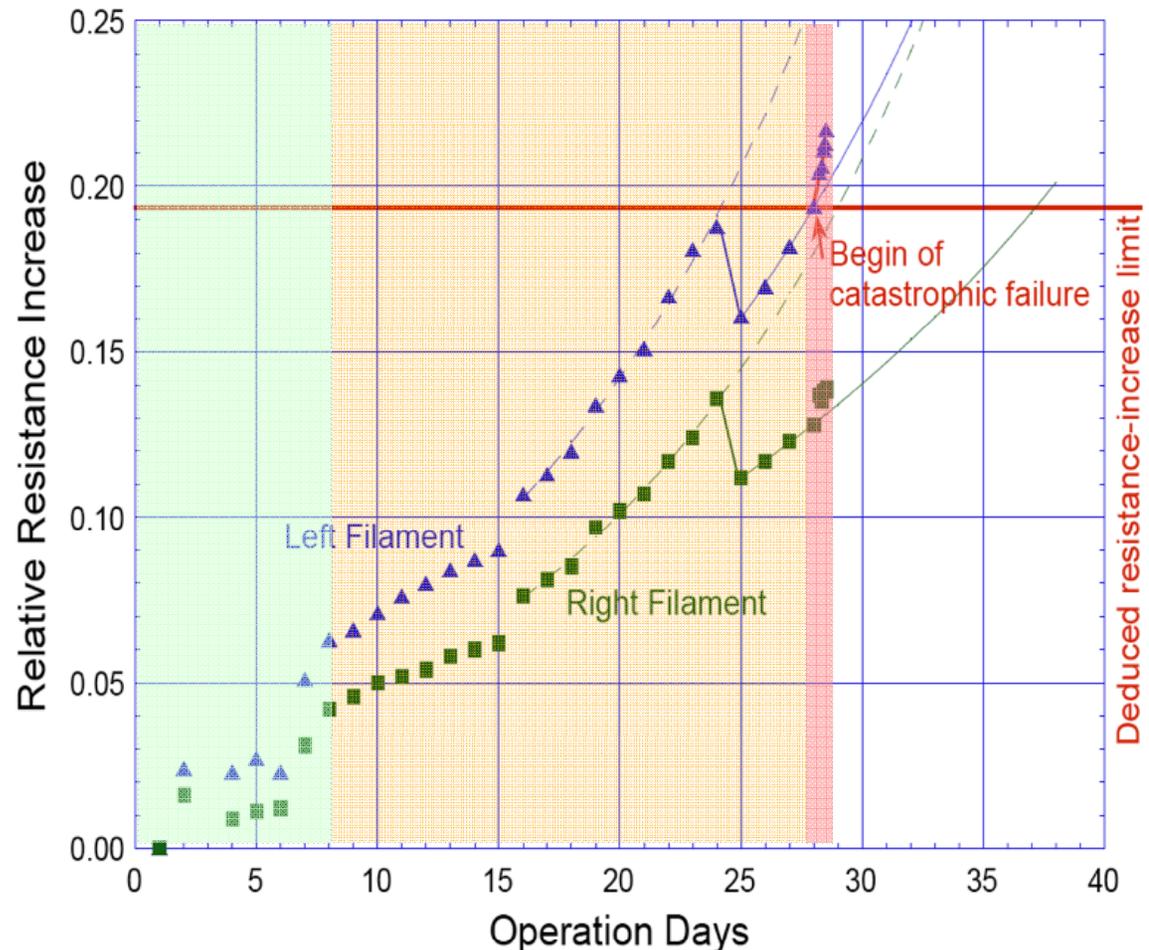
Data can be used to predict time of failure

-> Adjust filament heating power

Approach supported by analytical/computational model

Model shows **exponential growth and catastrophic failure**

0.05-mm 'nick' reduces lifetime by factor of 2



Typical resistance-increase plot – heating power was varied twice

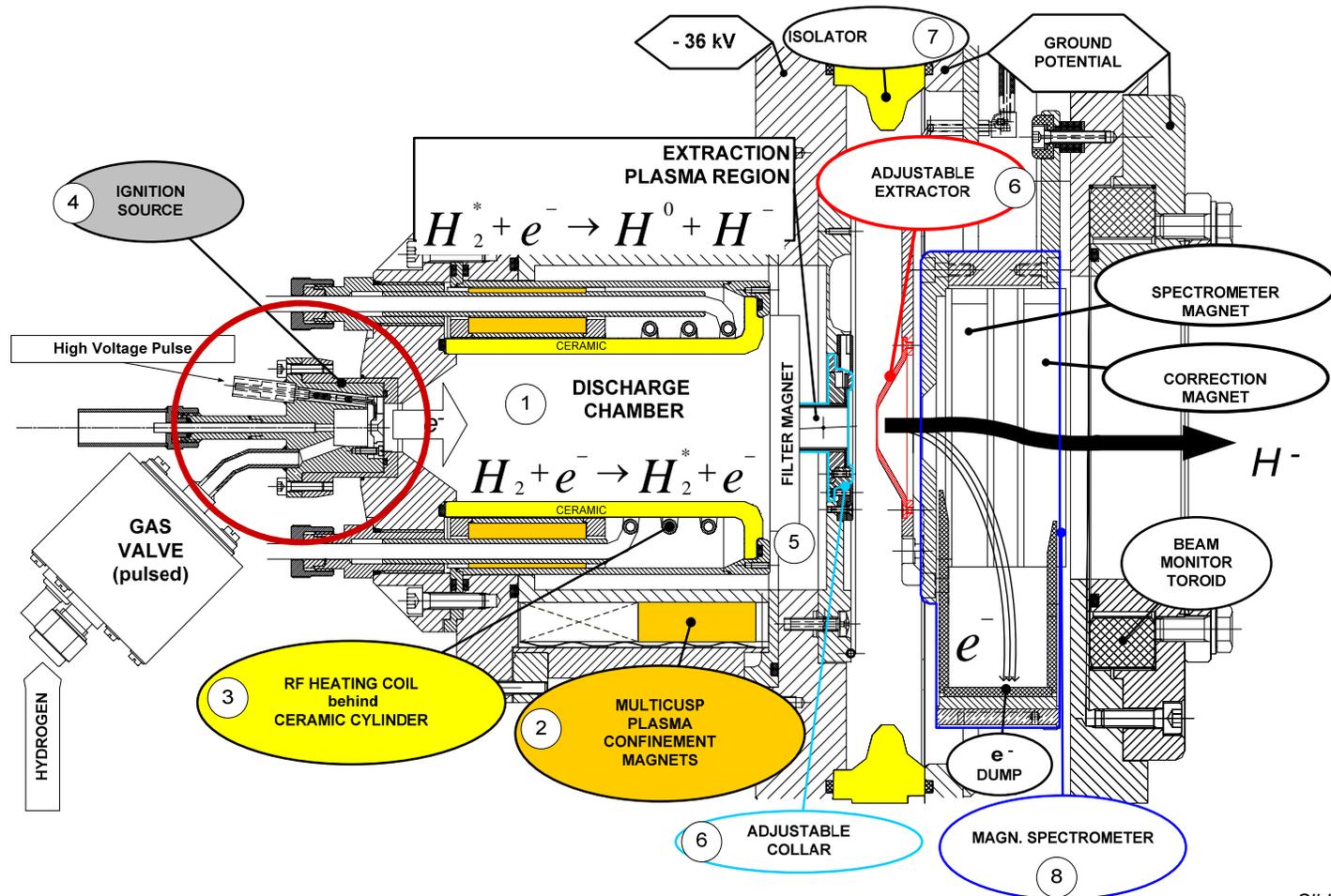
Rf Sustained Discharges (1)

Fundamentals

- **Typical frequencies 1-13.56 MHz**
- **No fast-eroding components such as filaments**
- **Need impedance matcher**
 - Amplifier typically 50 Ohm
 - Plasma about 1 Ohm
- **Ignition poses a problem**
 - Cw operation mode: Raise gas pressure for ignition
 - Pulsed operation mode: several options
 - Add low-power cw amplifier
 - Decouple power flow
 - Protect cw amplifier from reflected power as plasma impedance changes
 - Add spark-gap chamber or 'plasma gun' combined with pulsed gas valve

Rf Sustained Discharges (2)

'High' pressure discharge chamber added to facilitate ignition



Rf Sustained Discharges (3)

Antenna options

- **Antenna needs to be insulated from plasma**
 - Avoid arcing, meltdown
- **Internal antenna**
 - Porcelain coated
 - Single- or multi-layer
 - Incompatibility of thermal expansion coefficients leads to **cracks**
 - **Water/vacuum accident waiting to happen**
- **External antenna**
 - Major part of discharge chamber made from Al_2O_3 or, better AlN
 - Needs to be engineered for desired duty factor
 - Heat transfer
 - Maximum temperature gradient
 - May have to be protected from discharge heat load by Faraday shield

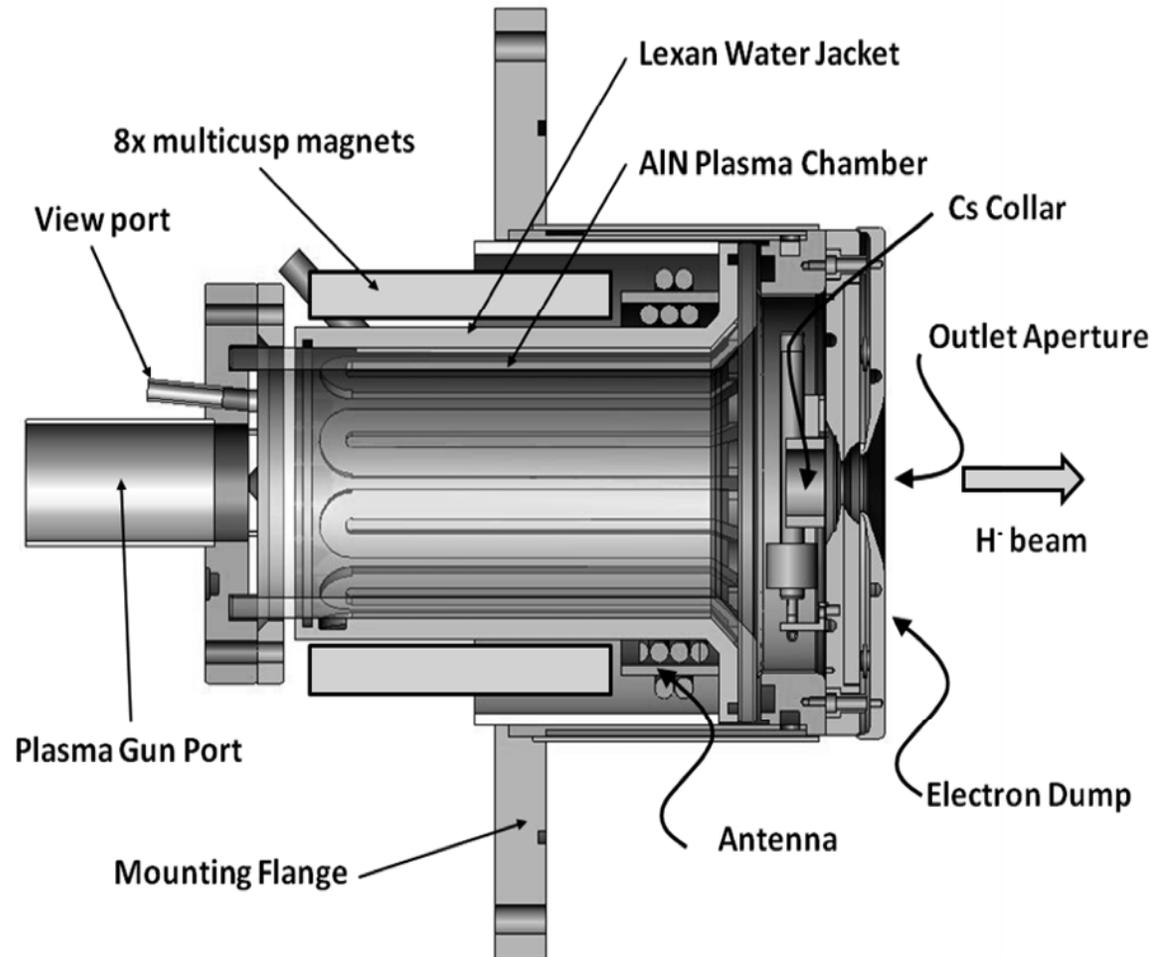
Rf Sustained Discharges (4)

Ion source with external antenna

SNS H⁻ Ion Source

1 ms/60 Hz pulsed operation

100 mA beam current
from 7-mm aperture

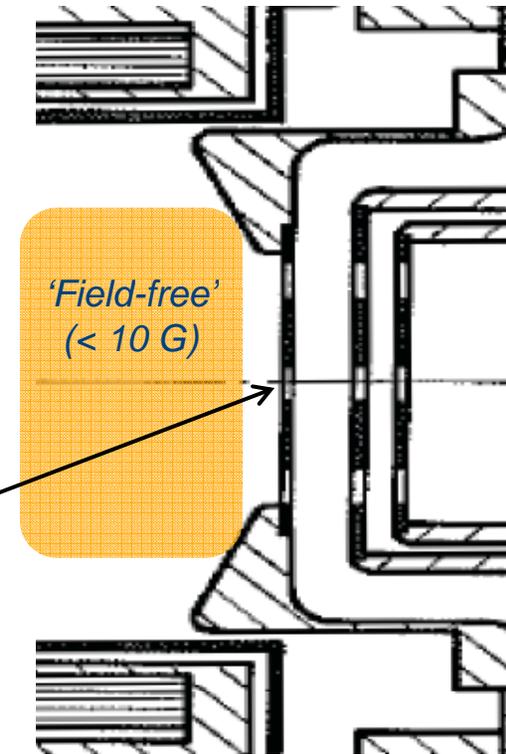


Multicusp ('Bucket') Sources (1)

Fundamentals

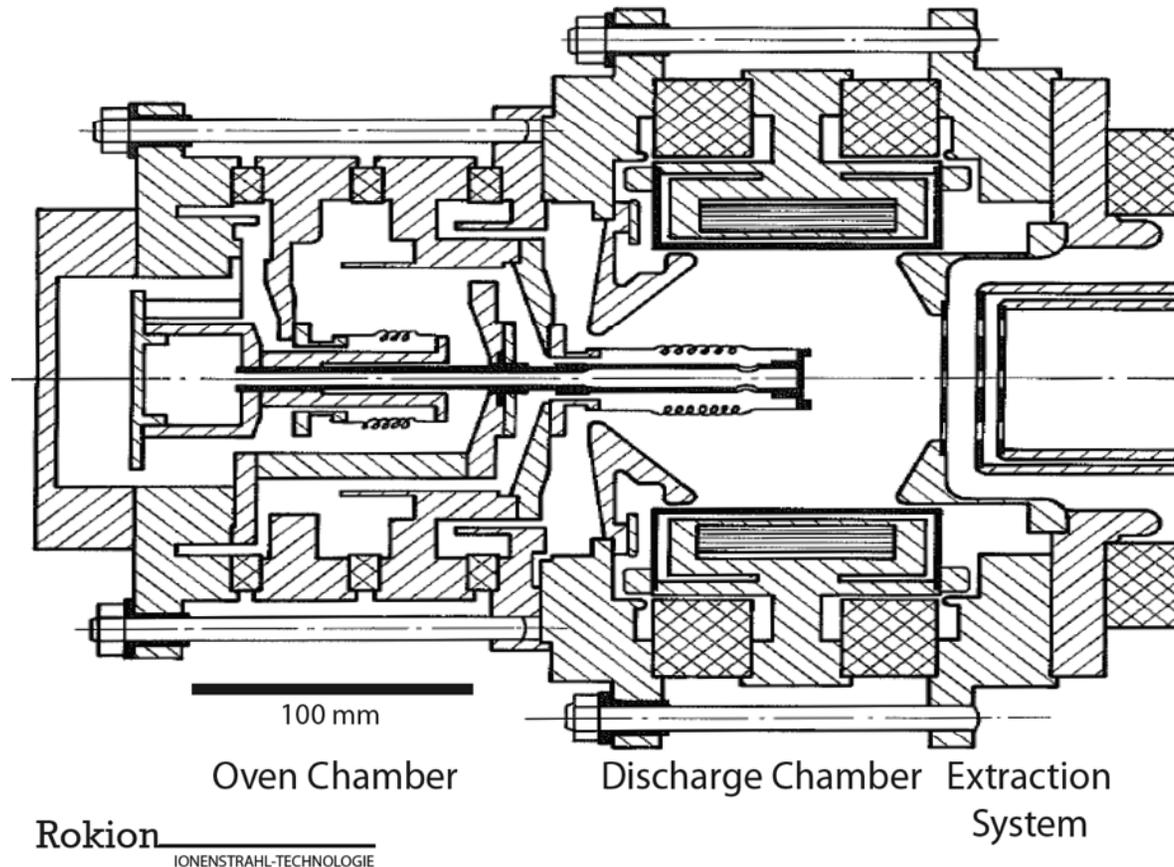
■ Stable plasma confinement achieved by minimum-B configuration

- Magnetic fields increase with increasing distance from discharge center
- Increases ionization probability for electrons
 - Significantly reduces plasma-loss area
- Facilitates space-charge compensation of extracted beam (no oscillations)
- Realized by lining discharge chamber with permanent magnets
 - High-current sources (8 – 20 magnets around)
- Permanent-magnet or electro-magnet sextupoles
 - > ECR sources
- Higher number of magnets enlarges 'field-free' cross-sectional area
 - Uniform plasma density allows use of wide multi-aperture extraction systems



Multicusp Sources (2)

Heavy ions



Conservative formula for single aperture, single ion species, single charge state:

$$I \text{ [mA]} = 0.5 A^{-1/2} U^{3/2} \text{ [kV}^{3/2}]$$

See: *R. Keller, 1984 Linac Conf.*

Multicusp Sources (3)

H⁺/D⁺ generation fundamentals

- **Need to be optimized for atomic ion (H⁺/D⁺) production**
- **Molecular ions compete for share in plasma**
- **Cannot simply push discharge voltage to optimum value as with multi-charged (heavy) ions**
- **Need to excite vibrational states of H₂/D₂ molecules**
 - Requires low-energy electrons
- **Install hot liner or BN liner**
 - Creates 'pre-dissociation'
- **Install magnetic dipole filter across discharge chamber**
 - Keeps energetic electrons from penetrating across filter field into secondary chamber
 - Low-energy electrons pushed through by elastic collisions, E×B drift
- **Alternative: ECR source (see below)**

Multicusp Sources (4)

H-/D⁻ generation fundamentals

- **Volume- and surface production, *see M. Bacal, Nucl. Fusion (2006)***
- **Volume production issues similar to (H⁺/D⁺) ion production**
 - Install magnetic dipole filter across discharge chamber
 - Keeps energetic electrons from penetrating across filter field into secondary chamber
 - Low-energy electrons pushed through by elastic collisions, E×B drift
 - Need to excite ro-vibrational states of H₂/D₂ molecules
 - Requires even lower low-energy electrons
- **Even 10-eV electrons and neutrals can destroy H-/D⁻**
 - Provide short paths to outlet aperture
 - Less-than-proportional scaling of beam current vs. aperture area
- **Surface production relies on resonant-tunneling charge-exchange of H-/D⁻ from surface with low work function**
 - Cesium Mo etc.
 - Barium

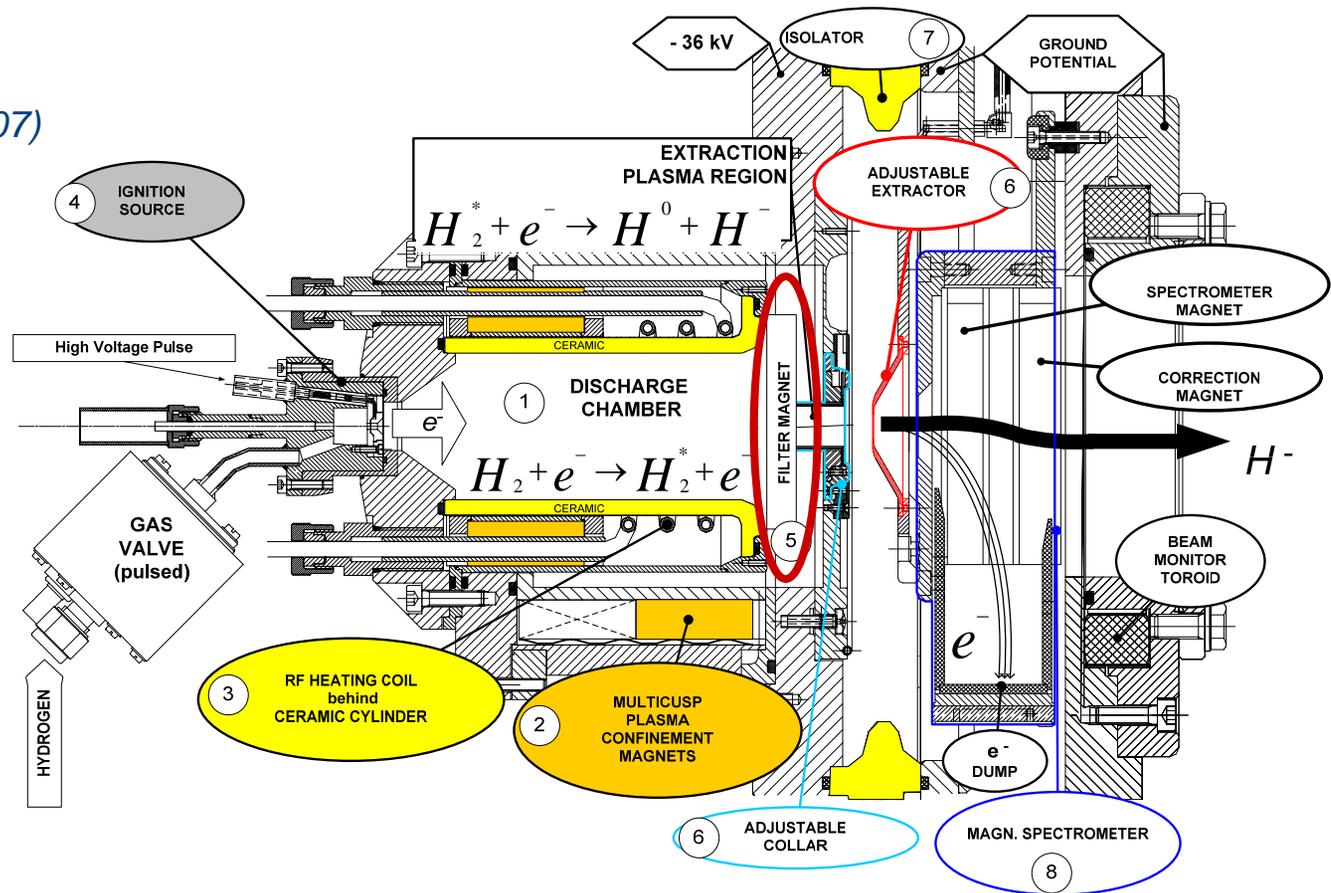
Multicusp Sources (5)

H-/D- generation by volume production

Multicusp source with magnetic dipole filter
(J. Peters, ICIS Conf. 2007)

Peak result

40 mA of H⁻ over 3 ms
Cesium-free



Multicusp Sources (6)

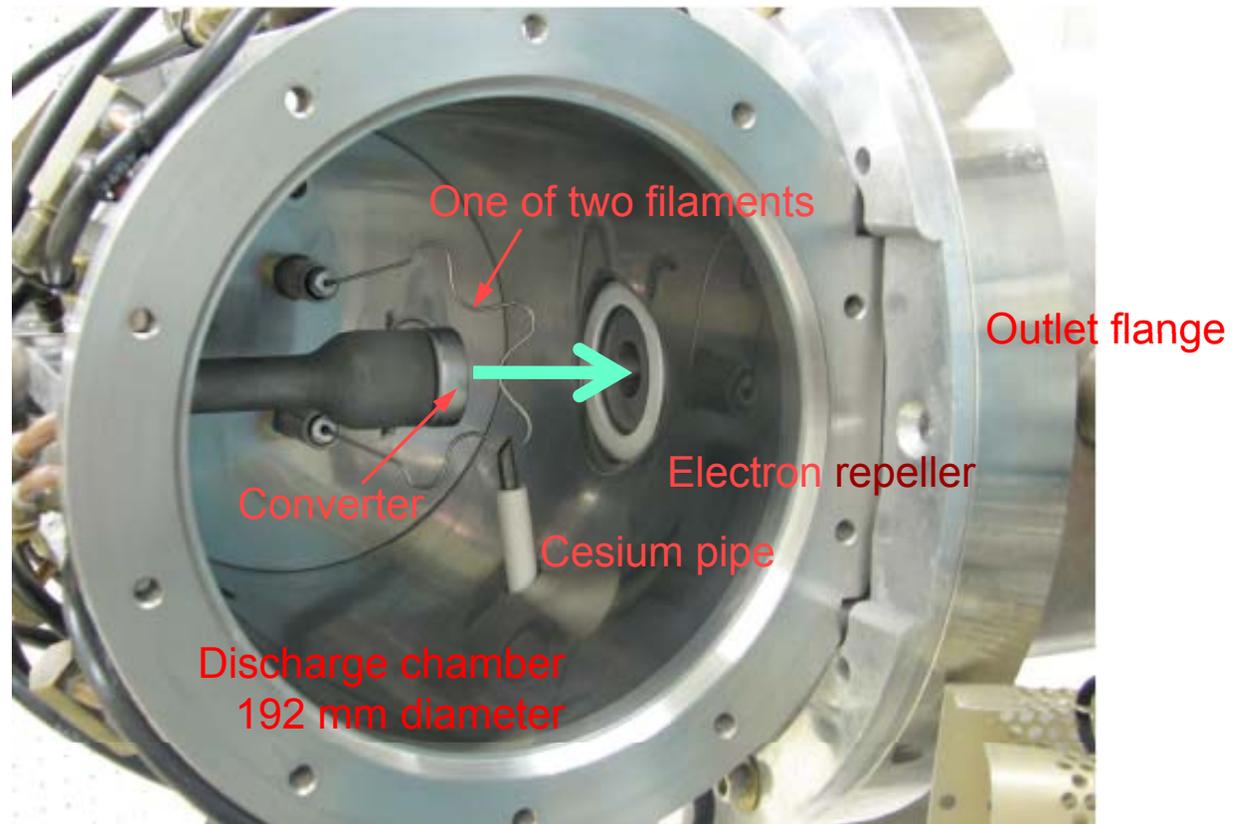
H-/D- Generation by surface production

LANSCCE H⁻ Ion Source
with cesiated, biased
converter

0.8 ms-60/120 Hz operation

Up to 25 mA beam current
from 9.8-mm aperture

300-eV beam energy
inside source



R. L. York, R. R. Stevens et al., LANL Los Alamos

Electron Cyclotron-Resonance Sources (1)

Fundamentals, see *R. Geller, ECRIS Workshop (1987)*

- **Filament-free**
 - Very long times-between-services even at cw conditions
- **Microwave driven in 2.45-28 GHz frequency range**
- **Longitudinal magnetic mirror field**
- **Resonance condition** $B_{\text{res}} [\text{T}] = 0.0354 f [\text{GHz}]$
- **Highly charged ions**
 - Low gas pressure $< 10^{-6}$ Torr
 - High density
 - **High** magnetic field for plasma confinement
 - **Low** magnetic field better for extracting more beam current
 - Transverse confinement by sextupole
 - Cut-off electron density $n_e [\text{cm}^{-3}] \leq 1.25 \times 10^{10} f^2 [\text{GHz}^2]$
- **High-current beams**
 - Higher gas pressure $\sim 10^{-3}$ Torr
 - Overdense wave penetration mode

Electron Cyclotron-Resonance Sources (2)

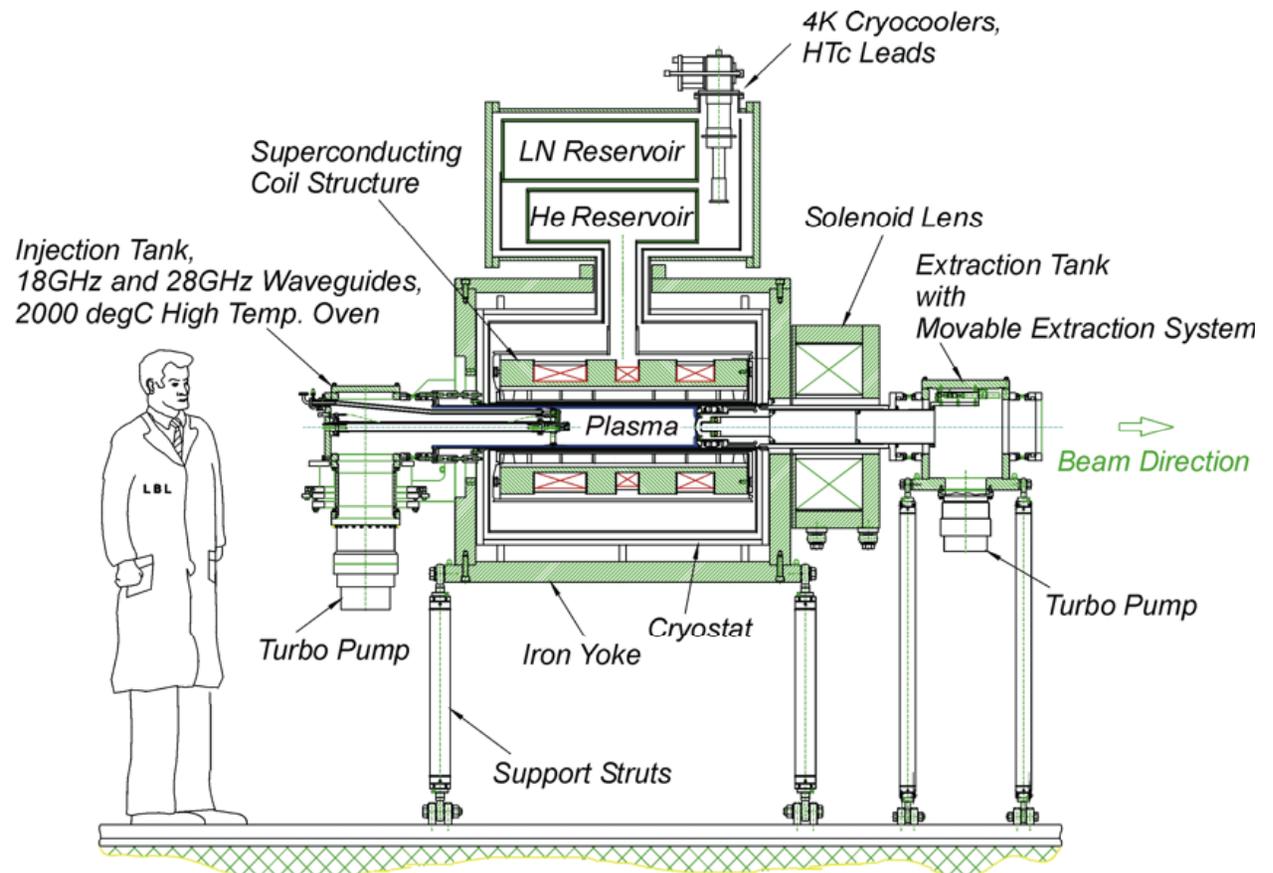
VENUS ECR Source for highly charged ions

Solenoid field 3.4 T peak
1 T resonance at 28 GHz

Sextupole field 2.1 T at
chamber wall

Peak results [electr. μ A]

$^{16}\text{O}^{6+}$	2850
$^{16}\text{O}^{7+}$	85
$^{129}\text{Xe}^{28+}$	222
$^{129}\text{Xe}^{38+}$	7
$^{238}\text{U}^{34+}$	202
$^{238}\text{U}^{35+}$	175
$^{238}\text{U}^{47+}$	5
$^{238}\text{U}^{50+}$	1.9



D. Leitner et al., LBNL Berkeley

Slide 21

Electron Cyclotron-Resonance Sources (3)

Issues and trends with ECR Sources for highly charged ions

- **Hollow-beam formation often noted**
 - Poor transport properties
- **X-ray generation becomes increasingly severe issue as plasma density, frequency and microwave power increase**
 - Requires external radiation shielding
 - Jeopardizes internal equipment (superconducting coils)
- **Ion production appears to depend on resonance volume**
 - Surface area of 'resonance cigar' times electron Larmor radius
 - Two-frequency microwave power
 - Broadband amplifier with Traveling-Wave Tube
- **Small frequency adjustments beneficial** - *L. Celona et al., ECRIS Conf. (2008)*
 - Improves microwave mode selection
 - Increased power efficiency, about 30%
 - Improved beam profile
 - Hollow triangle -> solid 'star'

Electron Cyclotron-Resonance Sources (4)

Charge Breeders

- **Serving Secondary Beam Facilities**
 - FAIR, RIA/FRIB
- **Collects radioactive ions from primary target**
- **Ionizes captured ions to higher charge states**
 - Improve efficiency of secondary accelerator
- **Main aspects**
 - Modular design minimizes radioactive waste upon turnover
 - Beam-current output depends on primary accelerator and target
 - Particle efficiency critical

Peak result from ANL Argonne, see G. Savard et al., ECRIS Conf. 2008

$^{133}\text{Cs}^{20+}$ at 3%
 $^{85}\text{Rb}^{15+}$ at 3.6% particle efficiency

Electron Cyclotron-Resonance Sources (5)

High-current ECR Sources

- **Penetration of microwaves into overdense plasma**

T. Taylor and J. S. C. Wills, Nucl. Instrum. Methods Phys. Res. A 309 (1991)

- Utilized by microwave driven proton source
 - 2.45 GHz frequency
 - About 1 kW cw power
 - 0.0875 T ECR resonance field
 - Solenoids or permanent magnets used
 - Beam optics similar to 'field-free' extraction systems
 - No transverse plasma-confinement configuration

Peak result from LEDA project, Los Alamos

120 mA transportable dc beam with 90% proton share from 8.6-mm outlet aperture

See J. D. Sherman et al., ICIS Conf. (2001)

Recent Ion Source Information

Meetings and Journals

- **International Conference on Ion Sources**
 - Rev. Scientific Instrum. 79 (2008, latest published issue)
- **International Workshop on ECR Ion Sources**
 - AIP Conf. Proceedings 749 (2005, latest published issue)
 - Latest workshop held 2 weeks ago in Chicago
- **International Conference on Negative Ions, Beams and Sources**
 - AIP Conf. Proceedings 925 (2007, latest published issue)
Meeting formerly called
Int. Symp. on Production and Neutralization of Negative Ions and Beams
- **Nucl. Instrum. Methods in Phys. Research A and B**
- **Physical Review Special Topics - Accelerators and Beams**
- **IEEE Transactions on Plasma Science**
- **Applied Physics Letters**